



1762

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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLI-  
CATION OF : O'Neill, et al

SERIAL NO. : 09/863,150 : GRP. ART UNIT: 1762

FILED : 05/23/2001 : EXAMINER:

FOR : Low Dielectric Constant Material and Method of Processing By CVD

Assistant Commissioner for Patents  
Washington, D.C. 20231

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Sir:

**TRANSMITTAL OF INFORMATION DISCLOSURE STATEMENT  
UNDER 37 C.F.R. 1.97(b)**

The Information Disclosure Statement submitted herewith is being filed within three months of the filing date of a national application other than a continued prosecution application under § 1.53(d); within three months of date of entry into the national stage as set forth in § 1.491 in an international application; before the mailing date of a first Office action on the merits; or before the mailing of a first Office action after the filing of a request for continued examination under § 1.114.

The cited reference, U.S. Patent No. 6,410,463, discloses at Example 2 a film having a dielectric constant of 2.49 formed from a mixture of DMDMOS, SiF<sub>4</sub> and He, however, no oxygen-providing gas (e.g., O<sub>2</sub>) is used in the production of the film, or any other film of the Examples.

Respectfully submitted,

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